1. INTRODUCTION

Zinc oxide (ZnO) is an interesting material as it is a semiconductor that has a large exciton binding energy of 60 MeV with a wide band gap of 3.4 eV at room temperature. The study of synthesis and growth of ZnO due to its size-dependent optical absorption is always a valuable tool. In fact, in an accessible size range experimentally, ZnO can show quantum confinement effects, unlike many oxides. Therefore, to quantum size ZnO particles, the best method to be used in cases like this is the sol-gel preparation method [1]. Not to mention ZnO has a low-temperature process in addition to cost savings, high carrier mobility, and transparency [1]. In the production and use of many chemical and pharmaceutical products, the most problematic matter is agglomeration. This aggregation immediately occurs when particles are generated in surfactant-free chemical reactions. To prevent aggregation, we have to embark from conventional colloid science in which particles are coated with foreign capping agents and/or the surface charges are tailored to separate them through electrostatic repulsions [2]. Because of its great fundamental and technological interest, it is always favorable to synthesize the ultrafine and controllable size particles with nanocrystalline structures [3].
Most surfactants have a hydrophilic (water-loving) head and a long hydrophobic (water-hating or oil-loving) tail, as shown in Figs. 1 and 2. We often describe surfactants is being amphiphilic molecules – they love everything [4]. Due to their capability to control crystal growth and to provide solubility, surfactants are widely used during the preparation of crystalline metal oxide in the nanoscale, which by organizing the small oxide crystallites into a controlled structure, they can maintain regular pores and low angle Bragg reflection [5]. Previous studies showed that cationic surfactants generally affect the morphology, size, and optical properties of metal oxides by controlling the particle’s growth. Cetyltrimethylammonium bromide (CTAB) is a common surfactant used in nanoparticle synthesis. One of CTAB’s uses is to direct the growth and stabilize the shape of nanoparticles [6]. Although the study on benzalkonium chloride (BAK) effect on metal oxide properties is still unknown but it has similar uses to other cationic surfactants [7]. However, the variety in the molecular structure of the surfactants was taken into consideration to choose BAK that consists of a head group and a double ring bi-tailed structure.

Several physical and chemical methods could be taken under consideration to synthesize ZnO nanostructures. Chemical vapor deposition (CVD), metal-organic CVD, and molecular beam epitaxy, pyrolysis, vapor-liquid-solid growth, and vapor-solid processes such as thermal reduction, are considered physical methods. At the same time, to have a very large scale production, there are chemical methods that are very simple yet effective such as precipitation, sol-gel, and solvothermal processes. Unlike general methods, these methods do not require high temperatures and sophisticated instruments [8]. In this work, the purpose is to synthesize a controllable grain size of particles, to approach that goal, the sol-gel method is the most convenient process, especially when we adjust these experimental conditions such as concentration, temperature, pH, and reaction time. Besides, its simplicity, this method is reproducible and cost affective, as well as its the reliability of stoichiometry control, which makes it a thoroughly suitable process for industrial production of ZnO [9].

2. EXPERIMENTAL

2.1. Apparatus
The tools that have been used in this experiment are silica crucible, measuring cylinder, electronic balance, filter tunnel, spatula, plastic wash bottle, beaker, Petri dish, desiccators, beaker (100–500 mL), volumetric flask (100–250 mL), plastic tubes, magnetic stir bar, hotplates, filter paper, forceps, gloves, containers, Pyrex glasses substrate, furnace, oven, and the centrifuge instrument.

2.2. Preparation of ZnO Nanoparticles without and with (CTAB) and (BAK) Individually
ZnO nanocrystals were prepared by adding 100.0 mL of 0.5 mol/l NaOH solution dropwise slowly into 250.0 mL of 0.1 mol/l Zn(Ac)₂ solution under vigorous stirring and closed vessel to produce the Zn(OH)₂ precipitate, then an appropriate amount of NH₄HCO₃ (0.8 g) powder was added. After stirring for 30 min, a semitransparent zinc carbonate hydroxide colloid was obtained. After 30 min, the colloid was centrifuged and
dried at 80°C. Thus, the precursor of a small crystallite of $\text{Zn}_3(\text{CO}_3)_2(\text{OH})_6$ with white color was formed then calcinated at 450°C for 2 h. Finally, the product was dried at 70°C to obtain the white-colored sample of ZnO nanoparticle.

In the case of CTAB, after adding NH$_4$HCO$_3$ powder then CTAB ($5 \times 10^{-3}$ M below, $9 \times 10^{-3}$ M at, $15 \times 10^{-3}$ M above) critical micelle concentration (CMC) was added individually. After stirring for 30 min, a semitransparent zinc carbonate hydroxide, CTAB colloid was obtained. After 30 min, the colloid was centrifuged and dried at 80°C. Thus, the precursor of a small crystallite of $\text{Zn}_3(\text{CO}_3)_2(\text{OH})_6$; CTAB with white color was formed. The precursor was then calcinated at 450°C for 2 h to obtain the sample. Finally, the product was dried at 70°C to obtain the white-colored sample of ZnO.

On the other hand, this time instead of CTAB, BAK (1 $\times$ 10$^{-5}$ M below, 5 $\times$ 10$^{-5}$ M at, 15 $\times$ 10$^{-5}$ M above), CMC were added one at a time. After stirring for 30 min, a semitransparent zinc carbonate hydroxide, BAK colloid was obtained. After 30 min, the colloid was centrifuged and dried at 80°C. Thus, the precursor of a small crystallite of $\text{Zn}_3(\text{CO}_3)_2(\text{OH})_6$; BAK with white color was formed. The precursor was then calcinated at 450°C for 2 h to obtain the sample. Finally, the product was dried at 70°C to obtain the white-colored sample of ZnO.

### 2.3. Determination of CMC of CTAB Surfactant

CMC value determination of the CTAB surfactant was done using the conductivity method. Experiment was taken place at 298 K using thermostated water bath. A CMC of the surfactant solutions was prepared using distilled water. These solutions were left for 15–20 min before being added to the ZnO synthesis precursor solution and measurements. The electrical conductivity was measured using conductivity meter, model ECCON1103K made from Singapore.

## 3. RESULTS AND DISCUSSION

### 3.1. CMC of CTAB

Fig. 3 shows that the CMC of CTAB was determined by plotting conductivity values against the concentration of surfactant solutions. The CMC value is obtained from the interception of two conductivity lines [11], the result was found to be 0.9 mM this result is near to that given in the literature data 0.89 mM [12]. The difference might be caused by taking the reading of conductivity meter before the conductivity meter could display a constant value. The CMC value of BAK was taken from literature data and it was 0.04 mM [13].

### 3.2. Analysis of Fourier Transformed Infrared (FTIR)

Fig. 4a shows the FTIR spectrum of prepared ZnO nanoparticles without CTAB. Furthermore, Fig. 4b-d shows the FTIR spectra of prepared ZnO nanoparticles in the presence of CTAB (below CMC, at CMC, and after CMC), respectively, while Fig. 5 shows the FTIR spectra of prepared ZnO nanoparticles in the presence of BAK (below CMC, at CMC, and after CMC), respectively. The broad absorption band centered above 3000 cm$^{-1}$ is attributable to the band O–H stretching vibrations of water molecules on ZnO, and the band near 1630 cm$^{-1}$ is assigned to the bond in H–O–H bending vibrations mode were also presented due to the adsorption of humidity in the air when FT-IR sample disks were prepared in an open air.

The spectrums near 1450 cm$^{-1}$ indicate the existence of C=O. The broad absorption band in the region 1030–1384 cm$^{-1}$ is assigned to C–H long-chain methyl, probably this is due to impurities like CTAB remnants. The existence of extra spectrums in Fig. 4b-d could indicate the unsuccessful removal of surfactant due to the calcination low temperature, which was 450°C and for 2 h. However, for ZnO samples with BAK surfactant, the calcination temperature was raised to 550°C for 5 h. The difference in the calcination temperatures and the time could explain the difference between the figures, and because of using two different surfactants, Fig. 4b-d of ZnO samples with CTAB surfactant is generally blue-shifted which means a decrease in wavelength [14] while Fig. 5 of ZnO samples with BAK surfactant is not blue shifted.

### 3.3. Analysis of Scanning Electron Microscopy (SEM)

The morphology of the prepared ZnO samples was determined by SEM analysis, as shown in Figs. 6-12,
ZnO samples with CTAB are calcined at 450°C for 2 h; demonstrate uniform but not the best morphology, due to impurities that have been investigated by FTIR results. ZnO samples with BAK are calcined at 550°C for 5 h, do not reveal uniform morphology. The structure of BAK is bulky and bi-tailed which is insoluble; the particles tend to agglomerate, which caused the increase in the particle size [15]. The particle sizes of ZnO sample were taken by line intersecting method; the result revealed that the prepared ZnO sample without CTAB and BAK in Fig. 4 was in the range of 80–85 nm which was larger than the prepared samples in the presence of CTAB (Figs. 7-9) and smaller than the prepared samples in the presence of BAK (Figs. 10-12), respectively. Among the other samples, the particle size of ZnO with CTAB at CMC, as shown in Fig. 8, was in the range of 55–60 nm. Both surfactants have a long chain of carbon included compound, in CTAB carbon may surround the zinc (Zn) particle or located between them, resulting in reduction of particle size and minimize the agglomeration of particles. Although SEM is not an accurate technique to determine the particle size, using line intersecting method according
to particle size distributions of ZnO nanoparticles based on SEM images, ZnO particles without surfactant reveal an average size of 86 nm, as shown in Fig. 13. The average size of samples with CTAB below CMC point is 84 nm. From both figures, it can be concluded that there is not a considerable change. Nevertheless, ZnO samples at CMC point demonstrate a smaller average size of 73 nm. The average size of samples with CTAB above CMC point is 80 nm, as shown in Figs. 14-16.

However, the results for ZnO samples with BAK revealed a bigger average size of 125 nm for ZnO with BAK below CMC point, 145 nm for ZnO with BAK at CMC point, and 212 nm for ZnO with BAK above CMC point. These samples are not nanosized, as shown in Figs. 17-19. The actual reason is due to BAK’s bulky structure which contains 25 carbon atoms in the tail that cause the agglomeration, as a result of this led to an increase in the size of the particles [15].

3.4. Analysis of Ultraviolet-Visible-Near-Infrared Spectroscopy

Figs. 20-26 illustrates the $\alpha h\nu$ versus $h\nu$ plot used for the estimation of the band gap of ZnO nanoparticles calcined at 550°C by extrapolating the graph to X-axis so as to calculate the band gap of the samples. The band gap is found to be 3.26 eV, 3.31 eV, 3.49 eV, 3.39 eV, 3.27 eV, 3.24 eV, and 3.21 eV for the samples prepared without surfactant and with both surfactants CTAB and BAK.
individually at different concentration (below, at, and after), respectively. The band gap increases in the presence of CTAB particularly at CMC point due to quantum size effects, as the size of a particle decrease, till it reaches a nanoscale, the decrease in confining dimension makes the energy levels discrete and this increases or widens
Fig. 16. Particle size distributions of zinc oxide nanoparticles with cetyltrimethylammonium bromide above critical micelle concentration.

Fig. 17. Particle size distributions of zinc oxide nanoparticles with benzalkonium chloride below critical micelle concentration.

Fig. 18. Particle size distributions of zinc oxide nanoparticles with benzalkonium chloride at critical micelle concentration.

Fig. 19. Particle size distributions of zinc oxide nanoparticles with benzalkonium chloride above critical micelle concentration.

Fig. 20. Band gap energy for zinc oxide nanoparticles without surfactant.

Fig. 21. Band gap energy for zinc oxide nanoparticles with cetyltrimethylammonium bromide below critical micelle concentration.

up the band gap and ultimately the band gap energy also increases [16], and decreases in the presence of BAK surfactant because of its bulky structure which contains 25 carbon atoms in the tails that cause the agglomeration. Although the results show two curves, which means impurities presence.

The following table (Table 1) reveals a comparison of band gap energy for each sample:
3.5. Analysis of X-Ray Diffractometer (X-Ray Diffraction [XRD])

Fig. 27 shows the XRD patterns of the ZnO nanoparticles calcined at 450°C for 2 h. A study of standard data JCPDS 76-0704 confirms that all the synthesized materials are hexagonal ZnO phase (wurtzite structure). The indexed spectrums of ZnO samples with CTAB at CMC, as shown in Fig. 28, have a high intensity and narrow width, which indicates that the products are well crystallized.

<table>
<thead>
<tr>
<th>Status</th>
<th>Band gap for ZnO: CTAB (eV)</th>
<th>Band gap for ZnO: BAK (eV)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Below CMC</td>
<td>3.31</td>
<td>3.27</td>
</tr>
<tr>
<td>At CMC</td>
<td>3.49</td>
<td>3.24</td>
</tr>
<tr>
<td>Above CMC</td>
<td>3.39</td>
<td>3.21</td>
</tr>
</tbody>
</table>

CTAB: Cetyltrimethylammonium bromide, ZnO: Zinc oxide, BAK: Benzalkonium chloride, CMC: Critical micelle concentration

**Fig. 22.** Band gap energy for zinc oxide nanoparticles with cetyltrimethylammonium bromide at critical micelle concentration.

**Fig. 23.** Band gap energy for zinc oxide nanoparticles with cetyltrimethylammonium bromide above critical micelle concentration.

**Fig. 24.** Band gap energy for zinc oxide nanoparticles with benzalkonium chloride below critical micelle concentration.

**Fig. 25.** Band gap energy for zinc oxide nanoparticles with benzalkonium chloride at critical micelle concentration.

**Fig. 26.** Band gap energy for zinc oxide nanoparticles with benzalkonium chloride above critical micelle concentration.
Fig. 27. XRD diffractogram of zinc oxide nanoparticles without surfactant.

The XRD pattern for the ZnO nanoparticle prepared without surfactant calcined at 450°C for 2 h is shown in Fig. 27. The three highest spectrums were assigned as (100), (002), and (101) matched planes for 2θ values of 31.769, 34.422, and 36.254°, respectively. The calculated average size of the most intense three diffraction spectrums was 76.9 nm. However, Fig. 29 is the XRD pattern for the ZnO nanoparticle prepared in the presence of CTAB below CMC calcined at 450°C for 2 h, recorded similarity matching with ZnO nanoparticles prepared without surfactant based on reference (JCPDS 76-0704). To estimate the average crystallite sizes of the prepared ZnO nanoparticle, Debye–Scherrer equation was used for the
(100), (002), and (101) planes corresponding to three exhibited broadened diffraction spectrums, and the average particle size was 74.1 nm (Fig. 29). This shows that the crystalline size becomes slightly smaller with increasing CTAB concentration.

The XRD pattern for the ZnO nanoparticle prepared in the presence of CTAB at CMC calcined at 450°C for 2 h, as shown in Fig. 27, recorded the similarity matching with ZnO nanoparticles prepared without surfactant based on reference (JCPDS 76-0704) but there was a difference in the spectrum broadening, the diffraction spectrums became broader, which indicates the consistent of smaller particle sizes. They were assigned as (100), (002), and (101) for the three highest spectrums matched planes for 2θ values of 31.769, 34.422, and 36.254°, respectively. The calculated average size of the most intense three diffraction spectrums was 68.0 nm. This shows that the crystalline size became smaller in the presence of CTAB at CMC concentration compared to the one below CMC. The reason is due to a large amount of surfactant monomers at CMC just before agglomeration and creating micelles. Moreover, the particles tend to agglomerate with the increase in CTAB surfactant concentration. Therefore, the amount of surfactant added was crucial in synthesizing ZnO with disperses particles. The surfactants create their own interface and form micelles at CMC [17]. Under the same conditions, micelle formation occurs in the bulk phase and surfactant-coated nanoparticles formed start to decrease by increasing surfactant concentration beyond the CMC point [18].

The XRD pattern of the ZnO nanoparticle prepared with BAK surfactant below CMC calcined at 550°C for 5 h is shown in Fig. 30. The three highest spectrums were assigned as (100), (002), and (101) matched planes for 2θ values of 31.769, 34.422, and 36.254°, respectively. The structure of synthesized material is hexagonal ZnO (Wurtzite structure) according to standard data JCPDS 76-0704. The calculated average size of the most intense three diffraction spectrums was 116.4 nm. Moreover, the structure was hexagonal as the others. On the other hand, Fig. 31 shows the XRD pattern of the ZnO nanoparticle prepared with BAK surfactant at CMC calcined at 550°C for 5 h. The three highest spectrums were assigned as (100), (002), and (101) matched planes for 2θ values of 31.769, 34.422, and 36.254°, respectively. The calculated average size of the most intense three diffraction spectrums was 130.0 nm.

The XRD pattern for the ZnO nanoparticle prepared with BAK surfactant above CMC calcined at 550°C for 5 h is shown in Fig. 32. The three highest spectrums were assigned as (100), (002), and (101) matched planes for 2θ values of 31.769, 34.422, and 36.254°, respectively. The calculated average size of the most intense three diffraction spectrums was 240.0 nm. As its obvious the particle size of ZnO samples in the presence of BAK increased due to the bulky and bi-tailed structure of BAK which causes agglomeration. The tail of BAK contains 25 carbon atoms, which causes agglomeration and leads to increase in particle size [15].

Fig. 29. XRD diffractogram of zinc oxide nanoparticles with cetyltrimethylammonium bromide below critical micelle concentration.
3.6. Analysis of Transmission Electron Microscopy (TEM)

TEM was used to determine the average particle size by Digital Micrograph software. The results that obtained by TEM image and TEM particle size distribution of ZnO sample without surfactant were 66 nm and 60 nm for ZnO with CTAB below CMC, 51 nm for ZnO with CTAB at CMC, 100 nm for ZnO with BAK below CMC, and 140 nm for ZnO with BAK at CMC, as shown in Figs. 33-42, respectively. As it is been mentioned in the previous investigations, the particle size of ZnO samples in the presence of BAK increased due to the bulky and...
Fig. 32. XRD diffractogram of zinc oxide nanoparticles with benzalkonium chloride above critical micelle concentration.

Fig. 33. Transmission electron microscopy image of zinc oxide nanoparticles without surfactant.

Fig. 34. Particle size distributions of zinc oxide without surfactant based on transmission electron microscopy.

Fig. 35. Transmission electron microscopy image of zinc oxide nanoparticles with cetyltrimethylammonium bromide below critical micelle concentration.

Fig. 36. Particle size distributions of zinc oxide with cetyltrimethylammonium bromide below critical micelle concentration based on transmission electron microscopy.
bi-tailed structure of BAK. The tail of BAK contains 25 carbon atoms, which causes agglomeration and lead to an increase in the particle size [15]. Among the samples, ZnO with CTAB at CMC has the smaller average particle size and starting to increase above CMC because the particles tend to agglomerate with the increase
in CTAB surfactant concentration. The surfactants create their own interface and form micelles at CMC. Therefore, the amount of surfactant added was crucial in synthesizing ZnO with dispersed particles.

The calculated particle sizes for each sample from XRD, TEM, and SEM are depicted in Table 2.

### 4. CONCLUSION

Among the prepared samples in the presence of CTAB at CMC, the prepared ZnO nanoparticles show uniform morphology, demonstrate a smaller size compared to the others, and the size increases with increasing CTAB concentration (after CMC), as the particles tend to agglomerate by increasing CTAB surfactant concentration. Moreover, with the addition of BAK surfactant, the particle size of all the samples starts to increase due to the carbon number in the structure of BAK which is for both tails is 25, which means surfactant activity becomes minimal and insoluble. Thus, solubility and practical surfactant properties are somewhat related. While the number of carbon atoms in the tail for CTAB is 17 at such level, a surfactant has good but limited solubility in water [15].

If the concentration of the surfactant was larger than the CMC, the surfactant formed micelles. When micelles are fully formed, the latter is not effective in dispersing the particles compared to monomers, which leads to an increase in particle size [19]. Agglomerations of particles occur in the micelle formation of surfactant, which results in larger particle size when the ratio of surfactant increases [19]. The indexed spectrums of ZnO with CTAB at CMC in the XRD spectrums have a high intensity and narrow width, which indicates that the products are well crystallized. Large band gap energy and highly blue-shifted absorption edge confirm that the synthesized ZnO nanoparticles in the presence of CTAB at CMC exhibit a strong quantum confinement effect [20].

### 5. ACKNOWLEDGMENTS

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### 6. AUTHORS’ CONTRIBUTIONS

Hwda Rauf was responsible for data collection and analysis and for preparing the manuscript draft. Hamid Rasheedi worked on the concept of the given study and on the final manuscript review. Both authors read and approved the final manuscript.

### REFERENCES


